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Oaza-Kadoma, Kadoma-shi, Osaka 5718686 (JP). MAT-  
SUI, Shinji [JP/JP]; 5-23-2, Tsujii 7-chome, Himeji-shi,  
Hyogo 6700083 (JP).

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(74) Agents: KOTANI, Etsuji et al; Nichimen Building 2nd  
Floor, 2-2, Nakanoshima 2-chome, Kita-ku, Osaka-shi, Os-  
aka 5300005 (JP).

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(71) Applicant (for all designated States except US): MAT-  
SUSHITA ELECTRIC WORKS, LTD. [JP/JP]; 1048,  
Oaza-Kadoma, Kadoma-shi, Osaka 5718686 (JP).

(72) Inventors; and

(75) Inventors/Applicants (for US only): FUKUSHIMA, Hi-  
roshi [JP/JP]; c/o MATSUSHITA ELECTRIC WORKS,  
LTD., 1048, Oaza-Kadoma, Kadoma-shi, Osaka 5718686  
(JP). KUBO, Masao [JP/JP]; c/o MATSUSHITA ELEC-  
TRIC WORKS, LTD., 1048, Oaza-Kadoma, Kadoma-shi,  
Osaka 5718686 (JP). INOUE, Akira [JP/JP]; c/o  
MATSUSHITA ELECTRIC WORKS, LTD., 1048,  
Oaza-Kadoma, Kadoma-shi, Osaka 5718686 (JP).  
TANAKA, Kenichiro [JP/JP]; c/o MATSUSHITA ELEC-  
TRIC WORKS, LTD., 1048, Oaza-Kadoma, Kadoma-shi,  
Osaka 5718686 (JP). MASUI, Mikio [JP/JP]; c/o  
MATSUSHITA ELECTRIC WORKS, LTD., 1048,

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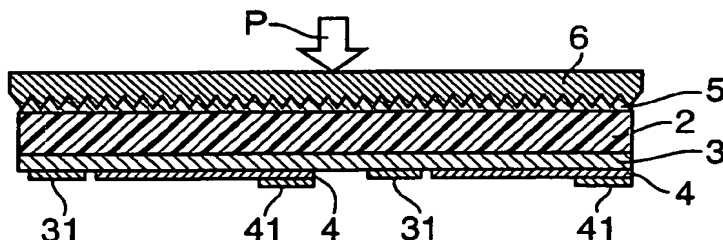
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ning of each regular issue of the PCT Gazette.

(54) Title: A METHOD FOR PRODUCING A LIGHT-EMITTING DEVICE



(57) Abstract: A production method for producing a light-emitting device 1 in which a light-emitting layer at least comprised of a n-type substrate bearing layer 3 and a p-type substrate bearing layer 4 is layered on a transparent crystal substrate 2 is provided with a step of forming a transfer layer 5 on at least a part of the transparent crystal substrate 2 or the light-emitting layer 3, 4, which transfer layer 5 is softened or set upon supplying an energy thereto; a step of pressing a mold 6 formed with a minute unevenness structure 61 against the transfer layer 5 to transfer the minute unevenness structure 61 to an outer surface of the transfer layer 5, and a step of forming a minute unevenness structure 21, 34 for preventing multiple reflection based on the minute unevenness structure 51 transferred to the transfer layer 5.

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